## IN THE CLAIMS

1. (Original) A device comprising:

more than one spring electrical contact to contact a first surface of an object, said first surface of said object to have a material electrodeposited thereon; and a base to directly support said first surface of said object without being directly connected to said spring electrical contacts, said base to distribute the force to seal a second surface of said object.

- 2. (Original) The device of claim 1 including a soft, acid resistant material disposed on said base.
- 3. (Original) The device of claim 1 wherein said base is spaced inward from said contacts.
- 4. (Original) The device of claim 1 wherein said spring electrical contacts are connected to a frame.
- 5. (Original) The device of claim 4 wherein said spring electrical contacts are resilient beams that terminate with tips.
- 6. (Original) The device of claim 5 wherein said object has an outer edge, said base to distribute a force at said object outer edge and said tips to contact said object inward from said base.
  - 7. (Original) The device of claim 4 wherein said base and said frame are annular.
- 8. (Original) The device of claim 4 wherein said frame and said beams are coated with an acid-resistant material.

- 9. (Original) The device of claim 1 wherein said base substantially continuously contacts said surface.
- 10. (Original) The device of claim 1 wherein said spring electrical contacts independently deflect while electrical contact is made with said object.
  - 11. (Original) A system comprising:
- a frame having spring electrical contacts to electrically contact a first surface of an object to enable electrodeposition on said object first surface;
- a base to directly support said object, said base and said frame not directly connected; and
- a sealing ring to seal a second surface of said object to prepare for electrodeposition.
- 12. (Original) The system of claim 11 including a plating cell to house said object for electroplating.
  - 13. (Original) The system of claim 12 including an electrode.
  - 14. (Original) The system of claim 13 including a power supply.
  - 15. (Original) The system of claim 14 including a thrust plate and a seal plate.
- 16. (Original) The system of claim 11 wherein said base is annular defining an annular aperture.
- 17. (Original) The system of claim 11 wherein said base is to distribute the force required to seal said second surface of said object.

- 18. (Original) The system of claim 11 wherein said object is a wafer and a metal or metal alloy is to be deposited on said first surface.
- 19. (Original) The system of claim 11 wherein said object is a wafer and copper or an alloy including copper is to be deposited on said first surface.
- 20. (Original) The system of claim 11 wherein said spring electrical contacts apply a variable force less than the force that if applied would exceed the mechanical strength of said object.
- 21. (Withdrawn) A method comprising:
  sealing a second side of an object to prepare said object for electrodeposition;
  directly physically supporting said object on a first side to enable said sealing;
  and

electrically contacting said first side of said object with spring electrical contacts to facilitate electrodeposition, said electrical spring contacts and said support not in direct contact.

- 22. (Withdrawn) The method of claim 21 including distributing the force to seal said second side of said object about the periphery of said object.
- 23. (Withdrawn) The method of claim 21 including applying a variable force with said spring electrical contacts to facilitate electrodeposition.
- 24. (Withdrawn) The method of claim 23 including determining the length and the maximum displacement of said spring electrical contacts.
- 25. (Withdrawn) The method of claim 21 including distributing the force to seal said second side of said object without exceeding the strength of said object first side.

- 26. (Withdrawn) The method of claim 21 including depositing a conductive material on said object first side.
- 27. (Withdrawn) The method of claim 26 including depositing a metal or metal alloy on said object first side.
- 28. (Withdrawn) The method of claim 21 including displacing adjacent spring electrical contacts with respect to said object first side.
- 29. (Withdrawn) The method of claim 21 including initially contacting said object with said spring electrical contacts, said initial contact having little or no associated force.
- 30. (Withdrawn) The method of claim 21 including electrically contacting said first side of said object without exceeding the strength of said object first side.